

LISTING OF THE CLAIMS:

Claims 1-10 (Cancelled)

Claim 11 (Previously Presented) An integrated semiconductor structure comprising a semiconductor substrate comprising a Group IV semiconducting material that has a (110) surface orientation and a notch pointing in a  $\langle 001 \rangle$  direction of current flow; and at least one PFET and at least one NFET located on the semiconductor substrate, said at least one PFET and said at least one NFET each having a device channel parallel to a surface of said semiconducting substrate, wherein said at least one PFET has a current flow in a  $\langle 110 \rangle$  direction and the at least one NFET has a current flow in a  $\langle 100 \rangle$  direction, said  $\langle 110 \rangle$  direction is perpendicular to the  $\langle 100 \rangle$  direction.

Claim 12 (Previously Presented) The integrated semiconductor structure of Claim 11 wherein said Group IV semiconducting material is selected from the group consisting of Si, SiGe, SiC, and SiGeC.

Claim 13 (Previously Presented) The integrated semiconductor structure of Claim 12 wherein said Group IV semiconducting material is Si.

Claim 14 (Original) The integrated semiconductor structure of Claim 11 wherein the at least one NFET and the at least one PFET each comprise a gate dielectric located on the semiconductor substrate, a patterned gate conductor located on portions of the gate dielectric, and spacers located on exposed sidewalls of the patterned gate conductor.

Claim 15 (Original) The integrated semiconductor structure of Claim 14 wherein the gate dielectric is an oxide.

Claim 16 (Original) The integrated semiconductor structure of Claim 14 wherein the patterned gate conductor comprises polySi.

Claim 17 (Original) The integrated semiconductor structure of Claim 11 wherein the at least one PFET and the at least one NFET each include source/drain regions, wherein the source/drain regions of the at least one PFET lie perpendicular to the source/drains of the at least one NFET.

Claim 18 (Cancelled)